Influence of Different Thicknesses on Mechanical and Corrosion Properties of a-C:H Films

Authors: S. Tunmee, P. Wongpanya, I. Toda, X. L. Zhou, Y. Nakaya, N. Konkhunthot, S. Arakawa, H. Saitoh

Abstract: The hydrogenated amorphous carbon films (a-C:H) were deposited on p-type Si (100) substrates at different thicknesses by radio frequency plasma enhanced chemical vapor deposition technique (rf-PECVD). Raman spectra display asymmetric diamond-like peaks, representative of the a-C:H films. The decrease of intensity ID/IG ratios revealed the sp3 content arise at different thicknesses of the a-C:H films. In terms of mechanical properties, the high hardness and elastic modulus values show the elastic and plastic deformation behaviors related to sp3 content in amorphous carbon films. Electro chemical properties showed that the a-C:H films exhibited excellent corrosion resistance in air-saturated 3.5 wt% NaCl solution for pH 2 at room temperature. Thickness increasing affected the small sp2 clusters in matrix, restricting the velocity transfer and exchange of electrons. The deposited a-C:H films exhibited excellent mechanical properties and corrosion resistance.

ISNI:0000000091950263

Keywords: thickness, mechanical properties, electrochemical corrosion properties, a-C:H film

Conference Title: ICMSME 2014: International Conference on Materials Science and Mechanical Engineering

Conference Location: Bangkok, Thailand Conference Dates: December 18-19, 2014

Open Science Index, Materials and Metallurgical Engineering Vol.8, No:12, 2014 waset.org/abstracts/11089